

**B. AMENDMENTS TO THE SPECIFICATION**

Please replace the paragraph beginning at Page 11, Line 26 with the following replacement paragraph (marked to show changes made, relative to the international application):

However, as wells penetrate the reservoir and gas reserves are depleted, the formation pressure drops continuously, inevitably to a level too low to induce gas velocities high enough to sustain stable flow. Therefore, all flowing gas wells producing from reservoirs with depleting formation pressure eventually become unstable. Once the gas velocity has become too low to lift liquids, the liquids accumulate in the wellbore, and the well is said to be "liquid loaded". This accumulation of liquids results in increased bottomhole flowing pressures and reduced gas recoveries. Injection of recirculated gas can effectively prevent or alleviate liquid loading, by increasing the upward velocity of the gas stream in the production chamber so as to maintain a gas velocity at or above the critical velocity for the well in question, thus maintaining velocity-induced flow. Methods and apparatus for gas injection for this purpose are described in the present Applicant's Canadian Patent Application No. ~~2,242,745~~ 2,424,745, filed on April 9, 2003 and corresponding International Application No. PCT/CA2004/000478, filed on March 30, 2004.